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DWG. NO.	DESCRIPTION	DWG. NO.	DESCRIPTION
VD49-0-001	P & ID LEGEND		

UNLESS OTHERWISE SPECIFIED DIMENSIONS ARE IN INCHES
 TOLERANCES:
 FRACTIONAL ±
 ANGULAR ±0.001
 TWO PLACE DECIMAL ±.01
 THREE PLACE DECIMAL ±.005
 FINISHED SURFACE ±.005
 BREAK CORNERS BY OUT-
 REMOVE ALL BURRS

REV	DESCRIPTION	CHKD	DRWN	DATE	DESB
1	REISSUED FOR FDR UPDATE			6/11/97	0499
0	ISSUE FOR FDR UPDATE	DMcV	TS	10.25.96	0309

PROCESS SYSTEMS INTERNATIONAL INC.
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PIPING & INSTRUMENTATION DIAGRAM
LIGO VACUUM EQUIPMENT
CHAMBER REPRESSURIZATION SYSTEM
 50 CFM & 100 CFM

CAD FILE: VD490007
 SHEET: D
 DWG. NO.: V049-0-007
 REV: 1

SCALE: NONE
 SHEET: 1 OF 1